

Summer Ethics Fellowship for Law Students and Recent Graduates

“I found it immensely valuable to think about ethics not only in the legal profession but in terms of how I as a legal practitioner may interact with business and journalism professionals in the course of my career.”

— **Miriam Marks, 2019 Law Fellow**



FASPE Law (Fellowships at Auschwitz for the Study of Professional Ethics in Law) is a fully-funded two-week summer program that uses the conduct of lawyers and judges in Nazi Germany as a launching point for an intensive study in contemporary legal ethics. **FASPE Law** is predicated upon the power of place. Fellows visit Auschwitz and other sites in Germany and Poland where they consider how to apply the lessons of history to the ethical challenges they will face in their careers.

In 2020 the program will take place from **May 22 - June 5**. All program costs are covered, including the equivalent of round-trip travel from New York to Europe, as well as all European travel, lodging and food. FASPE Law Fellows travel and share some seminars with Fellows in the FASPE Business and Journalism programs.

FASPE Law is open to current JD and LLM students and those who received a JD or LLM between May 2019 and January 2020. It is **designed to address ethical challenges in all fields of law**, including the **private sector, public interest organizations, and the government**.

To learn more about FASPE and to apply, please visit: <http://www.faspe-ethics.org>.

FASPE programs are non-denominational.

Candidates of all religious, ethnic, and cultural backgrounds are encouraged to apply.

FASPE staff is happy to talk with applicants concerned about potential conflicts with clerkships or bar preparation. For a list of previous Fellows, please visit <http://www.faspe-ethics.org/fellows-by-year>.

Completed applications are due by December 30, 2019.

FASPE

Fellowships at
Auschwitz
for the Study of
Professional Ethics

FASPE LAW

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www.faspe-ethics.org